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JC06 Rec'd PCT/PTO 03 MAY 200

101769-311-WCG

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants

Marc HUSEMANN, et al.

Serial No.

TBA (371 of PCT/EP03/012546)

Filed

Herewith (International Filing Date November 11, 2003)

For

POLY(METH)ACRYLATE-BASED PRESSURE-

SENSITIVE ADHESIVE

Art Unit

TBA

Examiner

TBA

May 3, 2005

Mail Stop PCT Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

SIR:

In accordance with 37 CFR §1.56, 1.97 and 1.98, Applicants wish to call the attention of the Examiner to the references listed on the accompanying form PTO-1449, copies of which are enclosed.

These references are relevant because they are cited in Applicants' specification, a Search Report of the German Patent Office in a corresponding application or in the International Search Report of the corresponding application. Copies of the German and International Search Reports are also enclosed.

Copies of U.S. patents are not included pursuant to 37 CFR § 1.98 (a) (2) (ii).

Applicants also note US and/or English language counterparts of non-English and/or foreign references as follows:

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DE 199 49 352	=	US 6,479,608
EP 0 728 165	=	No US equivalent
EP 0 728 166	=	US 5,602,221
EP 0 729 494	=	No US equivalent
EP 0 735 052	=	US 5,608,023
EP 0 758 274	=	US 5741542
EP 0 781 198	=	US 5558913
EP 0 824 110	=	US 5767210
EP 0 824 111	=	US 6114482
EP 0 826 698	=	English language abstract only •
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EP 0 850 957	=	US 5854364
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EP 1 188 802	=	US 5817426
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WO 95/13328	=	No US equivalent
WO 96/24620	=	US 5919871
WO 98/01478	=	US 2004171777
WO 98/13392	=	No US equivalent
WO 98/24978	=	US 6861141
WO 98/44008	=	US 6281311

It is believed no fee is due but, if it is, please charge the cost therefor against the account of the undersigned, Account No. 14-1263.

Consideration of the foregoing in relation to this application is respectfully requested.

JC06 Rec'd PCT/PTO 03 MAY 2005

Respectfully submitted,

NORRIS, McLAUGHLIN & MARCUS, P.A.

William C. Gerstenzang

Reg. No. 27,552

WCG:zs

Encs. - Form PTO-1449 References - 13 Abstracts - 2

875 Third Avenue, 18th Floor New York, New York 10022 (212) 808-0700 I hereby certify that this correspondence is being deposited with the United States Postal Services as Express Mail Label No. EV581553411US in an envelope addressed to Mail Stop PCT, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Zsuzsa Sønuste

Date May 3, 2005

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Page 1 of 2

LIST OF PATENTS AND PUBLICATIONS **APPLICANT'S INFORMATION**

DISCLOSURE STATEMENT (Form PTO-1449)

Attorney Docket: 101769-311-WCG

Applicants: Marc HUSEMANN, et al.

Filing Date: Herewith (International Filing Date November 11, 2003)

Group: TBA

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EXAMINER:

DATE CONSIDERED:

• EXAMINER: Initial if Reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformation and not considered, include copy of this form with next communication to applicant.

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